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July 15, 2003



MAIL STOP PATENT APPLICATION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Re: Application of Kouji TAKAHASHI and Hiroo ITOH
GLASS SUBSTRATE FOR A MASK BLANK, METHOD OF PRODUCING A
GLASS SUBSTRATE FOR A MASK BLANK, MASK BLANK, METHOD OF
PRODUCING THE MASK BLANK, TRANSFER MASK, AND METHOD OF
PRODUCING A TRANSFER MASK
Assignee: HOYA CORPORATION
Our Ref. Q76587

Dear Sir:

Attached hereto is the application identified above comprising thirty (30) sheets of the specification (Japanese Language), including the claims and abstract and three (3) sheets of drawings. **The requisite U.S. Government Filing Fee, executed Declaration and Power of Attorney, Assignment and English Translation will be submitted at a later date.**

The Government filing fee is calculated as follows:

Total claims	<u>19</u> - 20	=	<u> </u>	x	\$18.00	=	<u> </u>	\$0.00
Independent claims	<u>1</u> - 3	=	<u> </u>	x	\$84.00	=	<u> </u>	\$0.00
Base Fee								\$750.00
TOTAL FEE								<u>\$750.00</u>



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SUGHRUE MION, PLLC

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Priority is claimed from:

Country

Application No

Filing Date

JAPAN

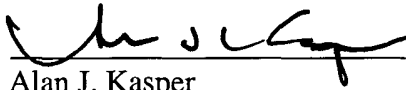
208049/2002

July 17, 2002

The priority document will be filed at a later date.

Respectfully submitted,
SUGHRUE MION, PLLC

Attorneys for Applicant

By: 
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PATENT TRADEMARK OFFICE

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